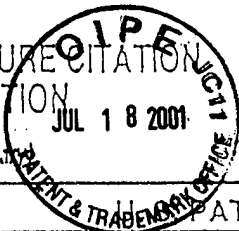


INFORMATION DISCLOSURE CITATION
IN AN APPLICATION

(Use several sheets if necessary.)



Document Number

TSMC-00-499

Application Number

09/845,477

Applicant

Chine-Gie-Lou

Filing Date

04/30/01

Group Art Unit

2812

PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	ALNO DATE & APPROPRIATE
MG	614021	6/10/31/00	Richart et al.	438	592	4/14/98
MG	5731239	3/24/98	Wong et al.	438	296	1/22/97
MG	6177336	8/1/23/01	Lin et al.	438	592	11/6/98
MG	6162691	12/19/00	Huang	438	300	3/29/99
MG	6146994	11/14/00	Hwang	438	633	4/26/99
MG	6153485	11/28/00	Pey et al.	438	305	11/9/98

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
					YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Portrort Pages, Etc.)

EXAMINER

Maria Guerrero

DATE CONSIDERED

6-14-02

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through